Contents lists available at ScienceDirect

Electrochimica Acta

journal homepage: www.elsevier.com/locate/electacta

Theory of Double Potential Step Chronoamperometry at Rough Electrodes: Reversible Redox Reaction and Ohmic Effects

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ARTICLE INFO

Article history: Received 8 November 2013 Received in revised form 19 February 2014 Accepted 19 February 2014 Available online 4 March 2014

Keywords: DPSC Nernstian or diffusion controlled charge transfer Finite Fractal Rough Electrode Ohmic effects

ABSTRACT

Theory is developed for the DPSC (double potential step chronoamperometry) response for finite fractal and nonfractal electrode roughness with and without uncompensated solution resistance. Mathematical equation for the statistically averaged current transient and its relation to surface structure factor of random roughness is highlighted for reversible charge transfer. Result shows the enhancement of current transient upto outer crossover time for the rough electrode. Current response after application of each potential steps can show upto three regimes, i.e. short, intermediate and long time regimes. In short time, when diffusion layer thickness is small, current response is controlled by the roughness factor. Crossover between short and intermediate time regimes is controlled by diffusion layer thickness scaled with mean square surface curvature. Current behavior in long time (after outer crossover time), when diffusion layer thickness is large compared to width of roughness, becomes identical to smooth electrode. Crossover between intermediate and long time regimes is controlled by mean square width scaled with diffusion layer thickness. For fractal roughness, current has anomalous power law behavior (in intermediate time regime) while for nonfractal roughness current shows crossover between two regimes. Increase in the ratio of reverse and forward current is usually understood as kinetic complications but here we show that this can also emerge out of electrode roughness. Uncompensated solution resistance correction is also included in our theory to account for realistic experimental conditions. Finally, results are compared with the experimental data of a reversible system in viscous medium.

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1. Introduction

Double potential step chronoamperometry (DPSC) is an effective approach to investigate electrochemical processes taking place at an electrode/electrolyte interface. DPSC has been a widely used electroanalytical technique for evaluation of quantity like concentration, diffusion coefficients, rate constants of homogeneous reactions, activation and inactivation rate constants of enzymes [1–3]. This technique offers criteria for determining whether kinetic currents are involved or not in an electrode process, to study adsorbed species on electrode surface, and is an excellent tool for the study of different types of mechanisms [2,4–7]. DPSC can be used for the quantitative determination of the migrational contribution to the current transient measured for redox systems [8]. DPSC is a powerful technique for the study of chemical reactions

following the electrode reaction, reactant and product adsorption at conventional-sized electrodes. A major characteristic of the method, is that the faradaic and charging currents can be easily separated [2,9–11]. Advantage of using DPSC than single potential step chronoamperometry allows simultaneous determination of the diffusion coefficients of the initial species, and the product of the electrochemical reaction [12]. This method is used extensively in applied systems like batteries, fuel cells, electrochromic films, bio-electrochemistry, water electrolysis etc. [6,13–18].

DPSC is special case of the result first obtained by Kambara [19,20]. For a reversible charge transfer system $O + ne^- \Rightarrow R$ occurring at electrode/electrolyte interface, current transient response for DPSC at planar electrode is described under semi-infinite linear diffusion condition. The current for forward step of diffusion limited process or Nernstian case at planar electrode/electrolyte interface is [10]:

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http://dx.doi.org/10.1016/j.electacta.2014.02.096 0013-4686/© 2014 Elsevier Ltd. All rights reserved.

$$I_{f}(t) = \frac{nFA_{0}D_{0}C_{0}^{0}}{\sqrt{\pi D_{0}t}(1+\xi\theta_{f})}$$
(1)





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A ₀	Geometric area
C^0_{α}	Bulk concentration of the oxidized species e.g. α =0,
	R
C	Surface concentration for forward step using Nernst
C 3	aquation
C	
C_p	Surface concentration for reverse step using Nernst
	equation
δC_0	Change in concentration of oxidized species
CR ^{Smooth}	P(t) Ratio of forward and reverse current for smooth
(D)	
CR(t)	Ratio of forward and reverse current for rough elec-
	trode
Di	Diffusion coefficient of i-th species e.g. $i = 0$. R
	Fractal dimension
E_{H}	Time dependent notential of the working electrode
E(l)	Time dependent potential of the working electrode
E_{f}	Potential of the working electrode at forward step
E_r	Potential of the working electrode at reverse step
E ^{0'}	Formal Potential
F	Faraday's constant
τ	Dunamic obmic loss function at smooth electrode
<i>J</i> =	Dynamic onnic loss function at smooth electrode
\mathcal{F}^*	Dynamic ohmic loss function at rough electrode
$\langle H^2 \rangle$	Mean square curvature of roughness
h	Width of interface
$\langle I_{-c}(t) \rangle$	Generalized Cottrell current at rough electrode
I(t)	Cottroll gurrant
$I_{\mathcal{C}}(t)$	
$I_f(t)$	Forward step current at smooth electrode
$I_r(t)$	Reverse step current at smooth electrode
I(t)	Total current transient at smooth electrode
$\langle I_{f}(t) \rangle$	Forward step current at rough electrode
(I(t))	Reverse step current at rough electrode
$\langle I_{f}(L) \rangle$	Total summent transient at rough electrode
$\langle I(L) \rangle$	Total current transient at rough electrode
$I_{C\Omega}(t)$	Current at smooth electrode with ohmic contribu-
	tion
$\langle I_{aO}(t) \rangle$	Current at rough electrode with ohmic contribution
<i>i</i>	Current density
J	Diffusion resistance length for forward stop
L_{Ω}	Diffusion-resistance length for forward step
L'_{Ω}	Diffusion-resistance length for reverse step
l	Lower cutoff length scale of a band-limited fractal
ℓ_{τ}	Topothesy length
L	Upper cutoff length scale or correlation length
mo	Zeroth moment of power spectrum
m0	Second moment of power spectrum
m_2	Second moment of power spectrum
n	Number of electrons transfered
ř	Vector (x, y, z)
$ec{r_{\parallel}}$	Vector (x, y)
Ro	Solution resistance
P	Cas constant
	Dunamia neurohnaga function for finite freetal sur
$K_F(l)$	
	faces
R _{nF}	Dynamic roughness function for nonfractal surfaces
$R_{C\Omega}$	Dynamic roughness contribution coupled with
	ohmic effects
\boldsymbol{p}^*	Poughness factor
ĸ	roughness factor
L	Time
t_0	Step size
to	Outer crossover time
ti	Inner crossover time
tr	Reverse sten time
-, t.	Forward step time
чf T	Torward step time
1	remperature
u(t)	Unit step function
Z	Coordinate representing distance away from elec-
	trode

$$\begin{split} \int d^2 K_{\parallel} & \int dK_x \int dK_y \\ \Delta E & (E_r - E_f) \\ \xi & \sqrt{D_0/D_R} \\ \hat{\zeta}(\vec{r}_{\parallel}) & \text{Arbitrary surface profile} \\ \nabla_{\parallel} & \hat{i}\partial_x + \hat{j}\partial_y \\ \langle |\hat{\zeta}(\vec{K}_{\parallel})|^2 \rangle & \text{Power spectral density} \\ \delta(t) & \text{Delta function} \\ \delta & D_H - 5/2 \\ \sigma & nF\Delta E/(RT) \\ \tilde{\chi}_r(t) & C_p/C_s \\ \Gamma, \gamma & \text{Incomplete Gamma function} \\ \mu & \text{Strength of proportionality} \\ \theta_{\beta} (\beta = f, r) & \exp[-nF(E_{\beta} - E^{0'})/RT] \end{split}$$

and the current during the reversal step is [10]:

$$-I_r(t) = \frac{nFA_0 D_0 C_0^0}{\sqrt{\pi D_0}} \left\{ \left(\frac{1}{1 + \xi \theta_f} - \frac{1}{1 + \xi \theta_r} \right) \left(\frac{1}{\sqrt{t - t_0}} \right) - \frac{1}{(1 + \xi \theta_f)\sqrt{t}} \right\}$$
(2)

where n is the number of electrons transferred in the reaction, F is Faraday's constant, A_0 is projected area of the surface, C_0^0 is the bulk concentration of oxidized species and t_0 is time period of each step, ξ is $\sqrt{D_0/D_R}$, D_0 and D_R are the diffusion coefficient of oxidized and reduced species, θ_{β} is exp $[-nF(E_{\beta} - E^{0'})/RT]$ where subscript β is f or *r*, representing forward and reverse step potential perturbation, respectively, R is the gas constant and T is the temperature. This representation of θ_{β} is different from the representation given in reference by Bard [10] (where $\theta_{\beta} = \exp[nF(E_{\beta} - E^{0'})/RT])$. In both representations positive net current taken as cathodic but in our representation when $(E_{\beta} - E^{0'})$ becomes more positive, cathodic current increases while in Bard's representation when $(E_{\beta} - E^{0'})$ becomes more negative, cathodic current increases. Difference in representation does not lead to any difference in current measurements. Bard representation of θ_{β} can be achieved by multiplying potential difference $(E_{\beta} - E^{0'})$ with negative sign. Using "unit step function (u(t))" [21] current for forward and reverse step can be written collectively as

$$I(t) = I_f(t)(u(t) - u(t - t_0)) + I_r(t)u(t - t_0)$$
(3)

where unit step function [21] is defined as

$$u(t) = \begin{cases} 1 & \text{for } t > 0 \\ 0 & \text{for } t \le 0 \end{cases}$$

Current *I*(*t*) will be equal to $I_f(t)$ for time $t \le t_0$ and *I*(*t*) will be equal to $I_r(t)$ for time $t > t_0$.

DPSC has been studied at various geometries (e.g. planar, spherical DME, SMDE and HMDE, microhemisphere, microdisk electrodes, UMEs etc. [24,1,4,5,11,12,22,23]). Above listed results are derived by considering that above mentioned solid geometries are smooth and electrode surface does not have any surface heterogeneity. Solid planar electrodes are not smooth, they exhibit complex surface morphology with varying degree of irregularity ranging from nanometer to micrometer length scales. Such complex unconventional geometrical disorder known to influence the electrode response [25–27]. The recent interest in surface disorder and finite fractal geometry has helped to understand the influence of electrode disorder on its response. Influence of roughness has been extensively studied on single potential step perturbation on chronoamperometric response [25–31]. Single potential

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